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(54) Title: NOZZLE ARRANGEMENT CONFIGURED TO FACE A SURFACE TO BE CLEANED

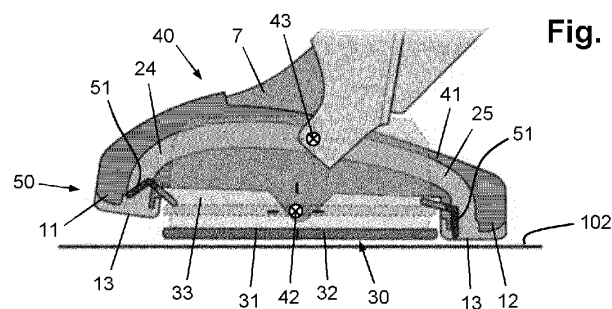


Fig. 11

(57) Abstract: A nozzle arrangement (7) that is configured to face a surface (102) to be cleaned comprises a first suction body (11) and a second suction body (12) located at a distance relative to each other. The nozzle arrangement (7) further comprises a level setting mechanism (40) that is configured to put the first suction body (11) and the second suction body (12) at different overall levels relative to the surface (102) in a normal, operational orientation of the nozzle arrangement (7) on the surface (102). In this way, cleaning performance of the nozzle arrangement (7) can be improved. Additionally or alternatively, it is possible to have a suction enhancing mechanism (50) for at least partially closing at least one of the first suction body (11) and the second suction body (12) to one of the surface (102) and an internal air conduit (24, 25) of the nozzle arrangement (7).

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